

**AMENDMENT****To the Specification:**

Please amend paragraph [0017] as following.

[0017] In order to achieve the above objects and other advantages of the present invention, a manufacturing method of a cover layer of an optical information storage media is provided. The method comprises providing a plate having a plain surface with a digital information structure or recording layer(s). Next, a reflective layer is formed on the substrate, a radiation-setting resin material is then applied on the reflective layer. Afterward, a plate is provided which having a flat surface, and then a poorly-adhesive layer is formed on the plate. The substrate and the plate are compressed with the ~~plate~~radiation-setting resin in-between, and the resulting structure is rotated in order to control the thickness of the radiation-setting resin layer. Next, the radiation-setting resin layer is hardened by illuminating the radiation-setting resin layer with an UV light, and then the plate is separated from the hardened radiation-setting layer. The hardened radiation-setting resin layer remains adhered to the substrate as a cover layer and the poorly-adhesive layer remains on the plate.